Introduction

Organic semiconductors based devices are advantageous compared to inorganic semiconductors because of their high absorption coefficients because most organic dyes emit in the visible range, making them suitable for very thin organic photo detector (OPD) and photovoltaic (OPV) applications. Other than this, some of the fluorescent dyes show strong red shifts during emission as compared to absorption and this property makes them perfect for organic light emitting diodes (OLEDs) with no absorption losses.

Organic semiconductor can be doped either by removing an electron from the highest occupied molecular orbital (HOMO) or by adding an electron to the lowest unoccupied molecular orbital (LUMO) to increase its conductivity. Doping in organic semiconductor creates high charge carriers which move in an electric field. This movement of charge is responsible for electrical conductivity in organic semiconductors.

Doping of a polymer is different than that of inorganic semiconductor, in which elements with an excess or shortage of electrons are introduced. In polymers, both doping processes involve both oxidation and reduction. The first method involves exposing a polymer to an oxidant, such as iodine or bromine, or reductant such as alkali metals.

The second is electrochemical doping in which a polymer-coated electrode is suspended in an electrolyte solution. The polymer is insoluble in the solution that contains separate counter and reference electrodes. By applying an electric potential difference between the electrodes, counter ions from the electrolyte are diffused into the polymer in the form of electron addition (n-doping) or removal (p-doping). One of the problems with organic semiconductors is that p-type material is more prevalent than n-type because electron rich n-type is unstable in the presence of oxygen. Organic semiconductors can only be useful for devices if both p-type and n-type are incorporated.

p-Type doping was realized by enhanced hole injection into matrix followed by the modification of the interfaces by Blom et al. They gave a new approach to understanding the effect of doping in organic semiconductors. Because the conductivity of any material is the product of carrier mobility and the number of charge carriers, increase in conductivity upon doping would result from the simultaneous increase of carrier concentration and carrier mobility. Generally, carrier transport in conducting materials takes place via hopping between the Gaussian density of states (GDOS). Consequently, if we ignore carrier density dependence, it will lead to an underestimation of the hopping distance and the width of the density of states in these systems.

p-Type doping of tetrafluorotetracyanoquinodimethane (F₄TCNQ) in poly(para-phenylene vinylene) (PPV) derivative “Super Yellow” (SY)

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In this paper, we report a case of hole transport in tetrafluorotetracyanoquinodimethane doped poly(para-phenylene vinylene) derivative “Super Yellow”. The hole mobility of pristine and doped polymer thin films was determined by impedance spectroscopy. The increase in hole mobility upon doping was also verified by current density–voltage measurements. It was found to be increased by two orders of magnitude upon doping. The increase in hole mobility upon p-type doping was explained on the basis of extended Gaussian disorder model by measuring current density–voltage characteristics in the same devices. At low bias, J–V characteristics exhibit clear space charge limited conduction in pristine state but ohmic behaviour when doped. Further, at higher voltages the current density increases non-linearly due to the field-dependent mobility and carrier concentration by filling of tail states of highest occupied molecular orbital of the host material. The room temperature J–V characteristics were well described with the single value of free hole density at low fields. At higher fields it becomes field-dependent followed by a field enhancement factor γ.
polymers. Therefore, a density dependent mobility model in combination with electric field and temperature has been proposed.\cite{16-18}

In this paper, we demonstrate the effect of p-type doping on the hole transport of Super Yellow (SY) in terms of carrier mobility and carrier density.

**Experimental**

For the hole transport study of SY polymer as a function of p-type doping, hole-only devices of SY polymer with different doping concentrations of F$_4$TCNQ were fabricated. SY and F$_4$TCNQ were dissolved in toluene under the concentrations of 6 mg ml$^{-1}$ and 0.1 mg ml$^{-1}$, respectively. The solutions were stirred on a hot plate at 70 °C for 12 h and then filtered separately. Then SY and F$_4$TCNQ solutions were blended in different doping concentrations by a volumetric pipette under nitrogen atmosphere. 25 µL dimethyl sulfoxide (DMSO) was added into the solutions to prevent aggregation. Further, hole only devices in the configuration of ITO/SY:F$_4$TCNQ/Au were fabricated. The devices were prepared on ITO coated glass substrates (purchased from Vin Karola, USA; sheet resistance ~18 Ω m$^{-2}$). Prior to use, the ITO coated glass substrates were cleaned by deionized water, acetone, trichloroethylene and isopropyl alcohol for 20 min and finally dried in vacuum. Thereafter, the active layer was spin coated onto these cleaned glass substrates from solution at a spin speed of 1200 rpm resulting in a typical film thickness of 200 nm.

These films were then annealed at 150 °C in vacuum for 2 h. On top of these films, Au electrodes of 500 nm thickness were deposited by vacuum thermal evaporation at $5 \times 10^{-6}$ Torr. The devices so obtained were sealed using UV irradiation on epoxy resin to inhibit atmospheric oxidation of electrodes. $J$–$V$ characteristics of the pristine and doped samples in different temperature ranges were measured using a low temperature setup coupled with a Keithley 2400 Source Meter unit interfaced with a PC. A Solartron SI 1260 Impedance/Gain-Phase analyzer was used to measure the capacitance–frequency ($C$–$f$) spectra of the samples.

**Results and discussion**

In this work, we studied the effect of doping on the hole transport of Super Yellow (SY). The hole mobility of pristine and doped SY thin films was determined independently from
Impedance spectroscopy (IS)\textsuperscript{19–22} by measuring frequency dependent capacitance spectra under varying applied biases.

We employed frequency dependent capacitance spectra for different applied d.c. biases ($V_{dc} = 5, 6$ and $7 \text{ V}$) by measuring the a.c. signal of $100 \text{ mV}$ over the frequency range $10 \text{ Hz}$ to $10 \text{ MHz}$.

Fig. 1(a–d) shows the capacitance spectra of pristine and doped devices as a function of a.c. frequency ($f$) from $100 \text{ Hz}$ to $1 \text{ MHz}$ for the d.c. bias voltages of 5, 6 and 7 V. Bias voltage is essentially required to drift/hop charge carriers (holes), which is otherwise not possible under the small a.c. test voltage of $100 \text{ mV}$. At higher frequencies, a sharp cutoff appears in $C-f$ spectra which approaches the vanishing point of the capacitance signal (see Fig. 1c). It is due to the reactive cutoff frequency of the structure. With increasing capacitance value, reactive cutoff frequency goes down.\textsuperscript{22,23} Because the capacitance value is the highest in Fig. 1c, its reactive cutoff frequency is the lowest. With the increase in the bias voltage, the capacitance–frequency spectra changed drastically at transit frequency ($f_t$). This may be due to the fact that the injected current lags behind the signal voltage due to the finite transit time ($\tau_{tr}$). Therefore, the injection of additional space charge increases with applied voltage and these injected charge carriers will further move into the device to achieve new equilibrium space-charge distribution. Because of the finite $\tau_{tr}$, the corresponding current lags behind the a.c. voltage, and this gives an inductive contribution to the capacitance. The amplitude of extremum point enhances and its position shifts towards higher frequencies with the increase of the bias voltage. This effect is more pronounced in doped samples as compared to pristine sample. At frequencies above the transit frequency, the period of applied a.c. field is too short to redistribute the space charge in the device. Hence, we used $C-f$ spectra at the intermediate frequency range to extract the carrier mobility where transit time effect occurs.

We estimated the hole mobility of pristine and doped hole only device by using the susceptance method.\textsuperscript{24–26} In this method, the peak in susceptance provides a definitive way for determining the transit time of the charge carriers in organic devices.
materials corresponding to the frequency ($f_{\text{max}}$) where susceptance shows peak. As the voltage across the sample is changed, the $f_{\text{max}}$ and hence the average transit time shifts enable the determination of mobility as a function of electric field. In this method, we extract the carrier transit time from susceptance plot, where negative differential susceptance is calculated as:

$$-\Delta B = \omega [C(\omega) - C_0]$$

where $\omega = 2\pi f$ is the angular frequency of the a.c. oscillations, $C(\omega)$ is the observed capacitance at a particular frequency and $C_0$ is geometrical capacitance of the organic layer ($C_0 = \varepsilon_0 A/L$, where $\varepsilon_0$ is the free space permittivity, $A$ is the area of plates and $L$ is the thickness of organic thin film).

The position of maximum of susceptance curves gives the transit time of hole ($\tau_{tr}$) according to eqn (2).

$$f_{\text{max}} = \frac{0.72}{\tau_{tr}}$$

In Fig. 2(a–d), we show the differential susceptance as function of the a.c. modulation frequency. The position and magnitude of the maximum of the $\Delta B$ curve are dependent on the bias voltage $V_{dc}$. When $V_{dc}$ increases, the peak shifts towards high frequency region and its amplitude grows. Using the peak positions of the $\Delta B$ curves at different applied voltages, the hole mobility in pristine and doped SY films was determined using eqn (3).

$$\mu_p = \frac{4 d^2}{3 L \tau_{tr} V_{dc}}$$

where $\mu_p$ is the hole mobility and $d$ is the thickness of the polymer films. The hole mobility was calculated to be $2.58 \times 10^{-8} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ to $2.40 \times 10^{-7} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ for pristine SY thin films, $5.34 \times 10^{-8} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ to $1.28 \times 10^{-7} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ for 1:600 doped SY thin films, $3.21 \times 10^{-7} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ to $2.71 \times 10^{-6} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ for 1:450 doped SY thin films and $6.80 \times 10^{-7} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ to $1.00 \times 10^{-6} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ for 1:300 doped SY thin films for $V_{dc}$ ranging from 5 to 7 volts. The mobility obtained in pristine sample is comparable to those measured by Bisquert et al. using the IS technique. These results are further supported by the d.c. measurements on the samples described in the forthcoming paragraphs.

For the d.c. analysis, we measured $J$–$V$ characteristics of pristine and doped SY samples at room temperature as well as elevated temperatures (230–290 K).

Fig. 3 shows the current density versus voltage ($J$–$V$) characteristics of SY hole only device with and without dopants at room temperature. At low bias voltages, the hole mobility ($\mu_p$) is constant and the $J$–$V$ characteristics follow the Child’s law given by:

$$J_{\text{SCLC}} = \frac{9}{8} \varepsilon_1 \varepsilon_0\mu_p \frac{V^2}{d}$$

where $J_{\text{SCLC}}$ represent space charge limited current density, $\varepsilon_1$ and $\varepsilon_0$ are the relative permittivity and free space permittivity respectively.

$J$–$V$ characteristics at low voltages has a slope of 1, i.e. it shows ohmic conduction. It is requisite condition that metal-semiconductor interface must be an ohmic contact to achieve space charge limited (SCL) conduction. Therefore, to confirm the hole injection property ITO/SY interface, the measured (observed) current density ($J_{\text{obs}}$) was compared with the current density expected ($J_{\text{cal}}$) from trap free space charge limited of negatively charge p-dopants. The injection efficiency ($\eta$) is given as:

$$\eta = \frac{J_{\text{obs}}}{J_{\text{cal}}}$$

The calculated injection efficiency was found to be $\sim 1$ and therefore the formation of an ohmic contact with SY was confirmed. Hence, we can directly calculate hole mobility from $J$–$V$ curves in the case of pristine as well as doped SY samples.

When $F_4$TCNQ is doped into polymer, free holes are generated into the polymer via p-type doping and these additional free holes are compensated by the negative charge of the corresponding acceptors. Therefore, doping induced free charge carriers will not contribute towards the space charge. Hence, in our calculations, we did not considered the effect of negatively charged p-dopants. Therefore, an ohmic-like current will flow at low voltages, given by:

$$J_{\text{II}} = q p_0\mu_p \frac{V}{d}$$
activated ionization process of the dopant, the mobility will not only depend on temperature but also on $p_0$, hence carrier density and mobility are included in eqn (6), to give eqn (7):

$$J_\Omega(V, T) = q p_0(T) \mu_p(T, p_0(T), E) \frac{V}{d}$$ (7)

Further, to investigate the conduction mechanism in doped SY samples, the $J$–$V$ characteristics were measured at various temperatures for doped SY devices with different doping ratios and are shown in Fig. 4(a–d). At low bias voltage the current density increases by 1–3 orders of magnitude with increasing doping concentrations. The solid lines with slope of 1 and 2 denote the ohmic and the space-limited current, respectively (it is already shown in Fig. 3 at room temperature, as doping concentration and field increases, more and more free charge carriers are generated and the ohmic-like current will flow already discussed in above section)). The $J$–$V$ characteristics were numerically modelled using a recently developed transport model. In this model, hole mobility depends on field $E$ and hole density $p$. The hole mobility is given by:

$$\mu_h(T, p, E) \approx \mu_h(T, p) f(T, E)$$

$$\mu_h(T, p) = \mu_0(T) \exp \left[ \frac{1}{3} (\sigma^2 - \bar{\sigma}) \left(2p\bar{\sigma}^3\right)^{\delta} \right]$$

$$f(T, E) = \exp \left\{ 0.44 \left( \frac{\sigma^{3/2}}{\bar{\sigma}} - 0.22 \right) \left[ \sqrt{1 + 0.8 \left( \frac{Ea}{\sigma} \right)^2} - 1 \right] \right\}$$

$$\delta = 2 \frac{\ln \left( \sigma^2 - \bar{\sigma} \right) - \ln (\ln 4)}{\sigma^2}$$

$$\mu_0 = \frac{\sigma^2 \nu_0 e}{\bar{\sigma}}$$ (8)
We observed similar effect with IS method as shown in Fig. 1. This result is attributed to the relatively low value of $\sigma$. Fig. 5 Electric field dependent free hole density ($p_\text{d}(E)$) at 230 K for 1 : 450% and 1 : 300% doped samples. For high doping concentrations, it is expected that the average distance that holes will have to hop from dopant to host will decrease.\textsuperscript{36}

The calculated $J$–$V$ data for all the devices were found to fit in the above model and parameters obtained from simulation are summarized in Table 1. The increase or decrease in transport parameters upon doping can be qualitatively understood on the basis of a simple model based on disorder.

Table 1 Comparison of calculated parameters from $J$–$V$ (space charge limited current) and susceptance method

<table>
<thead>
<tr>
<th>Samples</th>
<th>$J$–$V$ (SCLC) method</th>
<th>IS method at DC bias = 5 V</th>
<th>Disorder (meV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Pristine</td>
<td>$2.6 \times 10^{-7}$</td>
<td>$2.58 \times 10^{-8}$</td>
<td>0.046</td>
</tr>
<tr>
<td>1 : 600</td>
<td>$2.8 \times 10^{-7}$</td>
<td>$5.34 \times 10^{-8}$</td>
<td>0.044</td>
</tr>
<tr>
<td>1 : 450</td>
<td>$5.92 \times 10^{-7}$</td>
<td>$3.21 \times 10^{-7}$</td>
<td>0.041</td>
</tr>
<tr>
<td>1 : 300</td>
<td>$7.8 \times 10^{-7}$</td>
<td>$6.80 \times 10^{-7}$</td>
<td>0.040</td>
</tr>
</tbody>
</table>

where $\tilde{\sigma} = \sigma/\kappa_0 T$ and $\sigma$ is the width of the Gaussian density of states, $a (= 1/N^{1/2})$ is the inter site distance (in our case, $a = 1.29$ nm for SY), and $N$ is the density of transport sites. We found field-dependent mobility for pristine as well as doped SY samples as previously described in disordered materials in reports.\textsuperscript{34} The fittings of the experimental $J$–$V$ curves with eqn (8) are shown by the solid lines in Fig. 4a–d and fitting parameters are listed in Table 1. In our calculations, we took a field-dependent $p_\text{d}(E)$ with a Poole–Frenkel like dependence on the applied electric field\textsuperscript{35} The fittings of experimental $J$–$V$ curves is shown by the solid lines in Fig. 4a–d. These parameters fitted to $J$–$V$ curves for all devices and listed in Table 1. In our calculations, we have taken a field-dependent $p_\text{d}(E)$ with a Poole–Frenkel like dependence on the applied electric field\textsuperscript{35}

$$p_\text{d}(E) = p_\text{d}(E = 0) \exp \left( \gamma \sqrt{E} \right)$$

(9)

where $\gamma$ is the field-enhancement factor and $p_\text{d}(E = 0)$ is the zero field free hole density.

The field enhancement factor $\gamma$ is the dependent on both electric field and temperature. Fig. 5 shows the electric field dependent hole density as a function of temperature. We found that hole density dependence on field is strongest in 1 : 450 wt% SY:F\textsubscript{4}TCNQ doped sample as compared to other samples.

Fig. 5 Electric field dependent free hole density ($p_\text{d}(E)$) at 230 K.

Fig. 6 Schematic representations of the density of states and the position of the Fermi level in (a) pristine SY sample and (b) in SY doped with F\textsubscript{4}TCNQ. The red dashed line represents the LUMO level of F\textsubscript{4}TCNQ.
Conclusions

We demonstrated the hole conduction mechanism in SY thin films as a function of doping. The charge carrier mobility of SY thin films was determined using impedance spectroscopy of the pristine and doped SY thin films. F4TCNQ was used as a p-type dopant. The hole mobility was found to increase by 2 order of magnitude upon doping. It was observed that both mobility and carrier density increased with the doping of F4TCNQ in SY. The dependence of the hole mobility on doping was explained by combining space-charge limited, field-effect and carrier density dependent measurements. It was inferred that free carriers are generated from acceptor molecules.

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References